

Oxide Single Crystal Substrate

Shinkosha provides various optimal oxide single crystal substrates for epitaxial thin-film growth (Sapphire, SrTiO₃, Rutile, LaAlO₃ and NdGaO₃ are each treated in a separate catalog).

【Characteristics】 (Reference data)

Crystal	MgO	YSZ	LSAT	MgAl ₂ O ₄
Crystal system	Cubic	Cubic	Cubic	Cubic
Crystal structure	NaCl	CaF ₂	Perovskite	Spinel
Lattice constant	a = 0.4213 nm	a = 0.5139 nm	a = 0.7736 nm	a = 0.8083 nm
Melting point	2800 °C	2500 °C	1840 °C	2130 °C
Density	3.59 g/cm ³	6.05 g/cm ³	6.79 g/cm ³	3.64 g/cm ³
Thermal expansion	13.5x10 ⁻⁶ /°C	10.3x10 ⁻⁶ /°C	10x10 ⁻⁶ /°C	7.5x10 ⁻⁶ /°C
Dielectric constant	10	27	22	—

【Standard Specs】

Orientation tolerance	±0.5°
Size	10×10×0.5 mm , 15×15×0.5 mm (max : φ2in) Outer size tolerance : ±0.1 mm Thickness tolerance : ±0.05 mm
Surface roughness	R _a ≤ 1.0nm , R _{max} ≤ 5.0nm
Flatness	10×10×0.5mm: ≤λ , 15×15×0.5mm: ≤1.5λ (λ=632.8nm)

*This table is made for a general specification. Since it may differ from above specs depending on materials and orientations, please ask us for the details.

MgO	Orientation	Orientation flat	Size	One-side polishing	Both-side polishing
	(100)	(010)	10x10x0.5mm	○	○
	"	"	15x15x0.5mm	○	△

YSZ	Orientation	Orientation flat	Size	One-side polishing	Both-side polishing
	(100)	(010)	10x10x0.5mm	○	○
	"	"	15x15x0.5mm	○	△
	(111)	(110)	10x10x0.5mm	○	○

Yttria Stabilized Zirconia (Y₂O₃ ≈ 10mol%)

LSAT

(La_{0.3}Sr_{0.7})(Al_{0.65}Ta_{0.35})O₃

Orientation	Orientation flat	Size	One-side polishing	Both-side polishing
(100)	(010)	10x10x0.5mm	○	△
"	"	15x15x0.5mm	○	△

MgAl₂O₄

Spinel

Orientation	Orientation flat	Size	One-side polishing	Both-side polishing
(100)	(010)	10x10x0.5mm	○	△
(111)	(110)	10x10x0.5mm	△	△

○ : Standard △ : Made-to-order

If you are looking for different sizes, offset angle type and others, please contact us.
*Minimum order for made-to-order model and special model : 5pcs

Model Number

Orientation Flat

Crystal
 MgO : MO
 YSZ : YZ
 LSAT : LSAT
 MgAl₂O₄ : MA

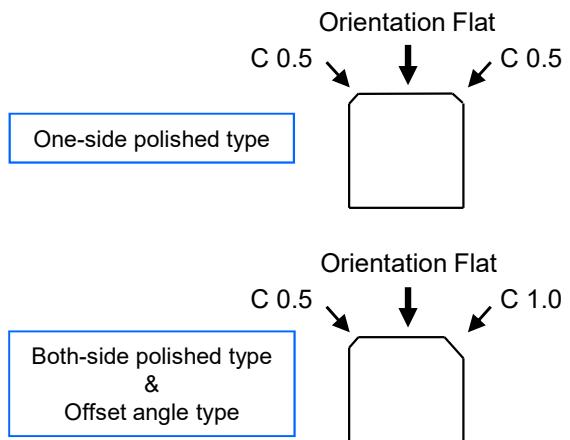
Polishing
 S : One-side
 W : Both-side

Surface treatment
 N : Normal

MO — AS — 10N

Orientation
 A : (100)
 D : (110)
 G : (111)

Size
 10 : 10 × 10 × 0.5 mm
 15 : 15 × 15 × 0.5 mm



<Visual check note>

We pass over the following:

- (a) Chips within 0.2mm from the circumference of substrates
- (b) Chips on the edge strip under 1/2 size of substrate thickness
- (c) Scratches and blemish on the back side of single-side polished substrates